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**FACSIMILE TRANSMISSION**

August 13, 2004

[062002-1751]

**TO**

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**FROM**

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**RE: 09/855,972**

(Message) Examiner Hassanzadeh, this is transmission 5 of 5.

**Number of Pages (Including This Cover Sheet): - 26 - Page(s)**  
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I hereby certify that this correspondence is being transmitted by facsimile to:

**ATTN: Parvis Hassanzadeh**  
**Facsimile number: 571 273 1435**  
**Commissioner for Patents**  
**P.O. Box 1450**  
**Alexandria, Virginia 22313-1450**

on August 13, 2004.

  
Eric Ringer

In re application of:	<b>Kevin P. Martin et al.</b>	Confirmation No.: <b>1603</b>
U.S. Serial Number:	<b>09/855,972</b>	Art Unit: <b>1763</b>
Filing Date:	<b>May 15, 2001</b>	Examiner: <b>Hassanzadeh, Parvis</b>
Our Reference Number:	<b>62002-1751</b>	

**Title: Method and Apparatus for Low Energy Electron Enhanced Etching or Substrates in an AC or DC Plasma Environment**

**1 Cited References (Articles Only)**